:			# 1163	SHEET 1 OF 3
FORM PTO-1448	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY, DOCKET NO. ASMINT,055AUS		APPLICATION NO. **10/890,215
P ETHEORMATION DISCLOSURE STATEMENT BY APPLICANT				
		APPLICANT Timmermans et at.		
HOW 1 0 MUNUS SEVERA	L SHEETS IF NECESSARY)	FILING DATE October 20, 2003		GROUP 2329 Z829

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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
D	1	3,011,006	11/28/61	Nicholson et al.	_	-	
80	2	3,874,919	4/1/75	Lehman	_	_	
g	3	4,374,158	2/15/83	Taniguchi et al.	_	_	
A	4	4,377,347	3/22/83	Hanmyo et al.		_	
El	5	4,389,967	6/28/83	Shimoda et al.	_		
8	6	4,428,975	1/31/84	Dahm et al.	_	-	
48	7	4,499,354	2/12/85	Hill et al.	_	-	
લી	8	4,522,849	6/11/85	Lewandowski	-	_	
50	9	4,592,307	6/3/86	Jolly	_	-	
C	10	4,633,051	12/30/86	Olson	_	_	
8	11	4,653,428	3/31/87	Wilson et al.	_	-	
R	12	4,692,556	9/8/87	Bollen et al.	_	_	
4	13	4,976,996	12/11/90	Monkowski et al.	_	_	•
40	14	4,978,567	12/18/90	Miller	_		
Q	15	4,984,904	1/15/91	Nakano et al.		_	
8	16	5,027,746	7/2/91	Frijlink	_	_	_
70	17	5,065,698	11/19/91	Koike	_	_	
B	18	5,104,514	4/14/92	Quartarone	_	_	
4	19	5,128,958	7/14/92	Nagashima et al.	_	-	
5 0	20	5,246,500	9/21/93	Samata et al.		_	
₹0 Ev	21	5,271,967	12/21/93	Kramer et al.	_		
Zr	22	5,315,092	5/24/94	Takahashi et al.		_	
8	23	5,336,327	8/9/94	Lee	_	~	<u> </u>
4	24	5,360,269	11/1/94	Ogawa et al.	_	~	
30	25	5,421,893	6/6/95	Perlov .	-	_	
5)	26	5,456,761	10/10/95	Auger et al.	-	~	
91	27	5,474,618	12/12/95	Allaire	_	_	

EXAMINER S	inh	DATE CONSIDERED 12/	18/04
EXAMINER: INITIAL IF C	ITATION CONSIDERED, WHETHER OR NOT CITAT	TON IS IN CONFORMANCE WITH MPE	609; DRAW LINE THROUGH CITATION IF NOT

IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.

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		r	SHEET 2 OF
FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE DISCLOSURE STATEMENT	ATTY. DOCKET NO. ASMINT.055AUS	APPLICATION NO. **10/690,215
(10 200 S)	Y APPLICANT	APPLICANT Timmermans et al.	
(USE SEVERA	L SHEETS IF NECESSARY)	FILING DATE ¹ October 20, 2003	GROUP 2829
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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME .	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
51	28	5,493,987	2/27/96	McDiarmid et al.	_	^	
81	29	5,514,439	5/7/96	Sibley	_	_	
EP	30	5,562,774	10/8/96	Breidenbach et al.	_	-	
4	31	5,571,333	11/5/96	Kanaya	_	^	
Ep	32	5,594,482	1/14/97	Ohashi		_	
Ep	33	5,728,629	3/17/98	Mizuno et al.	_	~	
2/	34	5,788,799	8/4/98	Steger et al.		-	
2/	35	5,798,016	8/25/98	Oehrlein et al.		-	
B	36	5,902,407	5/11/99	De Boer et al.		_	
21	37	5,904,778	5/18/99	Lu et al.	-	_	
20	38	5,910,221	6/8/99	Wu			
50	39	6,056,823	5/2/00	Sajoto et al.	_	-	
21	40	6,066,209	5/23/00	Sajoto et al.	_)	
50	41	6,071,573	6/6/00	Koemtzopoulos et al.	-	-	
Ee.	42	6,120,640	9/19/00	Shih et al:	_	~ .	
Ze	43	6,129,808	1,0/10/00	Wicker et al.	_		
28	44	6,170,429 B1	1/9/01 .	Schoepp et al.			
U	45	6,214,425	4/10/01	Spinelli et al.	_	~	
20	46	6,227,140 B1	5/8/01	Kennedy et al.	-		
٢	47	6,325,857	12/4/01	Miyoshi	~	_	•
21	48	6,325,858 B1	12/4/01	Wengert et al.	_	`	
21	49	6,342,691 B1	1/29/02	Johnsgard et al.	-		

l	EXAMINER	5/m	Rust	DATE CONSIDERED	12/	26/0	Y
				ATION IS IN CONFORMANCE WITH NEXT COMMUNICATION			THROUGH CITATION IF NOT

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FORM PTO-1449 U.S. DEPARTMENT OF COMME PATENT AND TRADEMARK OF INFORMATION DISCLOSURE STATEMENT		APPLICATION NO. **10/690,215
HOY 1 0 2003 (1)	APPLICANT Timmamans et al.	
(USE SEVERAL SHEETS IF NECESSARY)	FILING DATE October 20, 2003	GROUP 7879

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EXAMINER		DOCUMENT NUMBER	UMBER DATE COUNTRY CLASS SUB		SUBCLASS	S TRANSLATIO		
INITIAL							YES	Ю
. 20	50	WO 95/31582	11/23/95	PCT				
EP	51	WO 97/06288	2/20/97	PCT				
EP	52	WO 99/23276	5/14/99	PCT		-		
20	53	EP 0 229 488	7/22/87	EPO .	-	_		

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8	54	Linke et al., "Behavior of Boron-Doped Graphites, Plasma-Sprayed B ₄ C ₁ and a-C/B:H as Plasma-Facing Materials," Fusion Technology, Vol. 20, (September 1991), pp. 227-230.				
8	55	Moslehi et al., "Compositional Studies of Thermally Nitrided Silicon Dioxide (Nitroxide)," J. Electrochem Soc., Vol. 132, No. 9, pp. 2189-2197 (September 1985).				
50	56	Murarka et al., "Thermal Nitridation of Sillcon in Ammonia Gas: Composition and Oxidation Resistance of the Resulting Films," J. Electrochem. Soc., Vol. 126, No. 6, pp. 998-1003 (June 1979).				
50	57	Ponnekanti et al., "Failure mechanisms of anodized aluminum parts used in chemical vapor deposition chambers," J. Vac. Sci. Technol, Vol. 14, No. 3, (May/June 1998), pp. 1127-1131.				

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	AL IF CITATION CONSIDERED, WHETHER OR NOT				THROUGH CITATION IF NOT

#0207	SHEET 1 OF 1
ATTY, DOCKET NO. ASMINT,055AUS	APPLICATION NO. 10/890,215
APPLICANT Timmermans et al.	
FILING DATE October 20, 2003	GROUP 282\$

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
GP 1	5,874,368	10/20/03	Laxman et al.			

U.S. DEPARTMENT OF COMMERCE

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

PATENT AND TRADEMARK OFFICE

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FORM PTO-1449,

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DATE CONSIDERED

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